

**INFORMATION DISCLOSURE STATEMENT**

Case Name. M.S. Hodes 3-10-15-19-13-6
Serial No. 10/674448
Applicant: M.S. Hodes, et al.
Filing Date: September 30, 2003
Group:

U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Dat
/JN/	AA	10/403159		Komblit, A.			3/31/2003
/JN/	AB	10/649285		Komblit, A.			8/27/2003

FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation

OTHER (including Author, Title, Date, Pertinent Pages, etc.)

/JN/	AC	Kim, J., Kim, C-J., Nanostructured Surfaces For Dramatic Reduction Of Flow Resistance In Droplet-Based Microfluidics, IEEE 2002, pages 479-482

***References listed beyond AZ would list as AA-1, AB-2, AC-3 thru AZ-26.

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EXAMINER /Jyoti Nagpaul/	DATE CONSIDERED 04/24/2007
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/JN/	AA	6,185,961	2/13/2001	Tonucci, et al.	65	60.4	1/27/1999
	AB	US Pat. App. 10/798084		Arney, et al			3/11/2004
	AC	US Pat. App. 10/806543		Arney, et al			3/23/2004
	AD	US Pat. App. 10/816569		Gasparyan, et al.			4/1/2004
	AE	US Pat. App. 10/674448		Hodes, et al.			9/30/2003
	AF	US Pat. App. 10/803565		Hodes, et al.			3/18/2004
	AG	US Pat. App. 10/803641		Hodes, et al.			3/18/2004
	AH	US Pat. App. 10/403159		Kornblit, et al.			3/31/2003
	AI	US Pat. App. 10/649285		Kornblit, et al.			8/27/2003
	AJ	US Pat. App. 10/716084		Kroupenkine, et al.			11/18/2003
↓	AK	US Pat. App. 10/803576		Kroupenkine, et al.			3/18/2004
/JN/	AL	US Pat. App. 10/810774		Kroupenkine, et al.			3/26/2004

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OTHER (including Author, Title, Date, Pertinent Pages, etc.)

/JN/	AM	Kim, et al., "Nanostructured Surfaces for Dramatic Reduction of Flow Resistance in Droplet-Based Microfluidics," IEEE, pp. 479-482 (2002).

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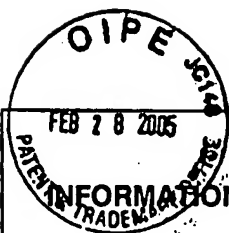
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*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date
/JN/	AA 2003/0148401	8/7/2003	Anoop Agrawal, et al	435/7.9	435/287.2	11/8/2002

FOREIGN PATENT DOCUMENTS

	Document Number	Date	Country	Class	Subclass	Translation
/JN/	AB DE 197 05 910	6/18/1998	EPC	B 01 L 3/00	H 01 L 49/00	No
↓	AC WO 03/071335	8/28/2003	PCT	G02B 27/00		Yes
↓	AD WO 03/083447	10/9/2003	PCT	G01N 13/02	B01L 3/00	Yes
↓	AE 0 290 125	11/9/1988	EPC	G02B 1/10		Yes
/JN/	AF WO 03/056330	7/10/2003	PCT	G01N 33/50		Yes

OTHER (Including Author, Title, Date, Pertinent Pages, etc.)

/JN/	AG	E. W. Becker, et al, "Fabrication of microstructures with high aspect ratios and great structural heights by synchrotron radiation lithography, galvanofarming, and plastic moulding (LIGA process)", <i>Micro-electronic Engineering, Elsevier Publishers BV., Amsterdam, NL</i> , vol. 4, no. 1, (5/1/1986), pp. 35-56.
/JN/	AH	European Search Report

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